

L Number	Hits	Search Text	DB	Time stamp
1	29	madou-marc-j-.in. modou-m-.in. modou-m-j-.in. modou-marc-.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 13:55
2	9519	430/311,312,313,320,322,323,328,396.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 13:56
3	1687	(microfluidic micro-fluidic micro adj fluidic) near2 device	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 13:58
4	20658	(electrochemical electro-chemical electro adj chemical) near2 cell	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 13:58
5	691697	resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:00
6	34557	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) with negative	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:08
7	8	((("4765864") or ("5130263") or ("4900405") or ("4874500")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:07
8	1	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) with negative) and (((("4765864") or ("5130263") or ("4900405") or ("4874500")).PN.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:05
9	3	(madou-marc-j-.in. modou-m-.in. modou-m-j-.in. modou-marc-.in.) and ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) with negative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:12
10	8	430/311,312,313,320,322,323,328,396.ccls. and (((microfluidic micro-fluidic micro adj fluidic) near2 device) ((electrochemical electro-chemical electro adj chemical) near2 cell)) and ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) with negative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:13
11	4889427	cavity channel microchannel micro-channel well microwell micro-well chamber	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:14
12	1618369	(laminat\$5 cover\$3) with (cover membrane)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:16
13	275609	(cavity channel microchannel micro-channel well microwell micro-well chamber) same ((laminat\$5 cover\$3) with (cover membrane))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:16
14	32931	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) near2 (first! bottom lower)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:16
15	32011	(resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) near2 (second! top! upper)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:17

17	1346	(cavity channel microchannel micro-channel well microwell micro-well chamber) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) near2 (first! bottom lower)) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) near2 (second! top! upper))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:19
16	140	((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) with negative) same ((cavity channel microchannel micro-channel well microwell micro-well chamber) same ((laminat\$5 cover\$3) with (cover membrane)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:20
18	44	(cavity channel microchannel micro-channel well microwell micro-well chamber) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) near2 (first! bottom lower)) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) near2 (second! top! upper)) same ((resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light radiation energy))) with negative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/05/23 14:21